

## ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

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### Title of Invention

METHOD OF FORMING STRAINED SI/SIGE ON INSULATOR  
WITH SILICON GERMANIUM BUFFER

Application Number :

Confirmation Number:

First Named Applicant: Huajie Chen

Attorney Docket Number: FIS920030381US1

Art Unit:

Examiner:

Search string: ( 6603156 or 6524935 ).pn

### US Patent Documents

**Note: Applicant is not required to submit a paper copy of cited US Patent Documents**

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	6603156	2003-08-05	Rim			
	2	6524935	2003-02-25	Canaperi, et al.			

### Signature

Examiner Name	Date